	Туре	Hit s	Search Text	DBs	Time Stamp	en	De fi	Errors	Ref #
1	BRS	16	stack\$ with semiconductor near layer with selective near etch\$5	HEPO! JPO!	2005/03/20 00:13				S3
2	BRS	136		EPO: JPO:	2005/03/20 00:14				S4
3	BRS	15	with selective	18°P() • .1 P() •	2005/03/20 00:18				S5
4	BRS	7		EPO; JPO;	2005/03/20 00:26				s7
5	BRS	163	with etch\$5 with	IB D() • . I D() •	2005/03/20 00:26				S8
6	BRS	127	selective with	IEPO · JPO ·	2005/03/20 00:26				S9

	Туре	Hit s	Search Text	DBs	Time Stamp	en	Dе	Er	Ref #
7	BRS	11	etch\$5 with	IN' D() • . I D() •	2005/03/27 23:40				S10
8	BRS		selectiv\$4 with etch\$5 with lateral\$4 and optic\$5 and air near gap	EPO; JPO;	2005/03/27 23:48			:	S11
9	BRS	4	nateral 4 and	18: P() * .1 P() *	2005/03/27 23:52				S12
10	BRS	7	lateral\$4 and fill\$4 with air near gap	HEPO!	2005/03/27 23:50				S13
11	BRS	12	·	EPO: JPO:	2005/03/27 23:56				S14

	Туре	Hit s	Search Text	DBs	Time Stamp	en	De	Errors	Ref #
12	BRS	44	stack with alternat\$4 and selectiv\$4 with etch\$5 with lateral\$4	EPO. JPO.	2005/03/28 00:13		•		S15
13	BRS	146	IETCHSO WITH	B.PO: APO:	2005/03/28 00:14				S16
14	BRS	22	lateral\$4 same	IP.PO: JPO:	2005/03/28 00:23				S17
15	BRS		etch\$5 with lateral\$4 same	M.PO: JPO:	2005/03/28 00:23				S18
16	BRS		fill\$5 and optic\$4 and air near gap	H.PO' (PO'	2005/03/28 00:23				S19
17	BRS	1	etch\$5 near lateral\$5	H.P(): (1P(): 1	2005/03/28 00:26			,	S20
18	BRS	2	selectiva4 near	IB.PO: TPO: I	2005/03/28 00:27				S21

	Туре	Hit s	Search Text	DBs	Time Stamp	en	Er ro r De fi ni ti	Er ro rs	Ref #
19	BRS	70	selectiv\$4 near etch\$5 near lateral\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:28				S22
20	BRS	3	("438"/\$).ccls. and stack\$ and selectiv\$ near etch\$5 near lateral\$ and optic\$	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:41				S24
21	BRS	12	("438"/\$).ccls. and etch\$5 near lateral\$ and optic\$ and vcsel	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:44				S25
22	BRS	r e		US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:48				S23
23	BRS	83	epitaxial near liftoff and optic\$	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:51				S26
24	BRS	19	MODELCS and air	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:51				s27
25	BRS ··	1.8	llitoii and etchs near	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/03/28 00:52				S28